Method of Managing Wafer Defects

Appl. No. : 10/711,310 Confirmation No.: 5309

Applicants : Hung-En Tai,

Chia-Yun Chen,

Sheng-Jen Wang

Filed: September 9, 2004

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Examiner : CHAWAN, SHEELA C

Docket No. : LKSP0051USA

Customer No.: 27765

Commissioner for Patents

P.O. Box 1450

Alexandria VA 22313-1450

AMENDMENT

Sir:

In response to the Office action of October 19, 2007, please amend the above-identified application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 4 of this paper.

10 Remarks/Arguments begin on page 7 of this paper.